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(12) **United States Patent**
Chang(10) **Patent No.:** **US 6,950,158 B2**(45) **Date of Patent:** **Sep. 27, 2005**(54) **TRANSFLECTIVE LIQUID CRYSTAL
DISPLAY DEVICE AND FABRICATION
METHOD THEREOF**(75) Inventor: **Ching Chao Chang**, Taipei (TW)(73) Assignee: **Hannstar Display Corp.**, Taipei (TW)(*) Notice: Subject to any disclaimer, the term of this
patent is extended or adjusted under 35
U.S.C. 154(b) by 38 days.(21) Appl. No.: **10/787,484**(22) Filed: **Feb. 26, 2004**(65) **Prior Publication Data**

US 2005/0001959 A1 Jan. 6, 2005

(30) **Foreign Application Priority Data**

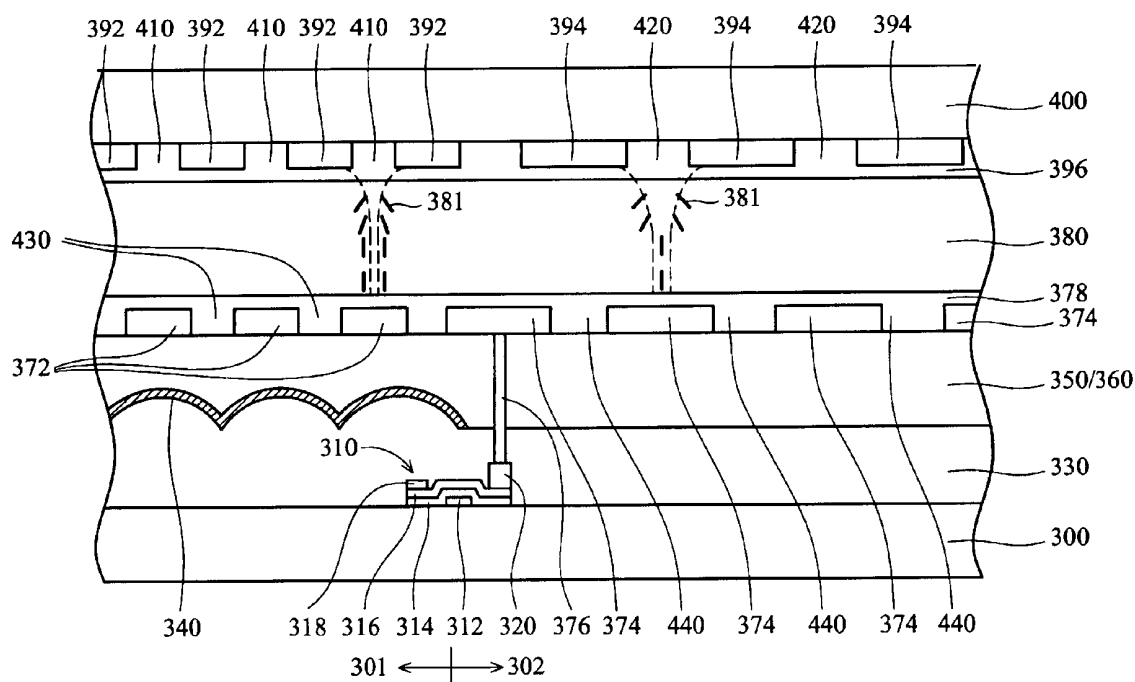
May 12, 2003 (TW) 92112785 A

(51) **Int. Cl.**⁷ **G02F 1/1335; G02F 1/1337**(52) **U.S. Cl.** **349/114; 349/129; 349/130**(58) **Field of Search** 349/114, 129,
349/130(56) **References Cited**

U.S. PATENT DOCUMENTS

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* cited by examiner*Primary Examiner*—James A. Dudek(74) *Attorney, Agent, or Firm*—Thomas, Kayden,
Horstemeyer & Risley(57) **ABSTRACT**

A transflective LCD device with a single cell gap. First and second pixel electrodes are formed on the lower substrate. First and second common electrodes are formed on an inner surface of the upper substrate. The first pixel electrodes and the first common electrodes are located in the reflective region. The second pixel electrodes and the second common electrodes are located in the transmissive region. A first orientation control window having a slit width " S_{rc} " is formed between the first common electrodes in an area corresponding to each first pixel electrode. A second orientation control window having a slit width " S_{tc} " is formed between the second common electrodes, satisfying $S_{rc} < S_{tc}$. The second orientation control window is in an area corresponding to each second pixel electrode. Accordingly, maximum light efficiency can be achieved in both reflective and transmissive modes.

44 Claims, 6 Drawing Sheets

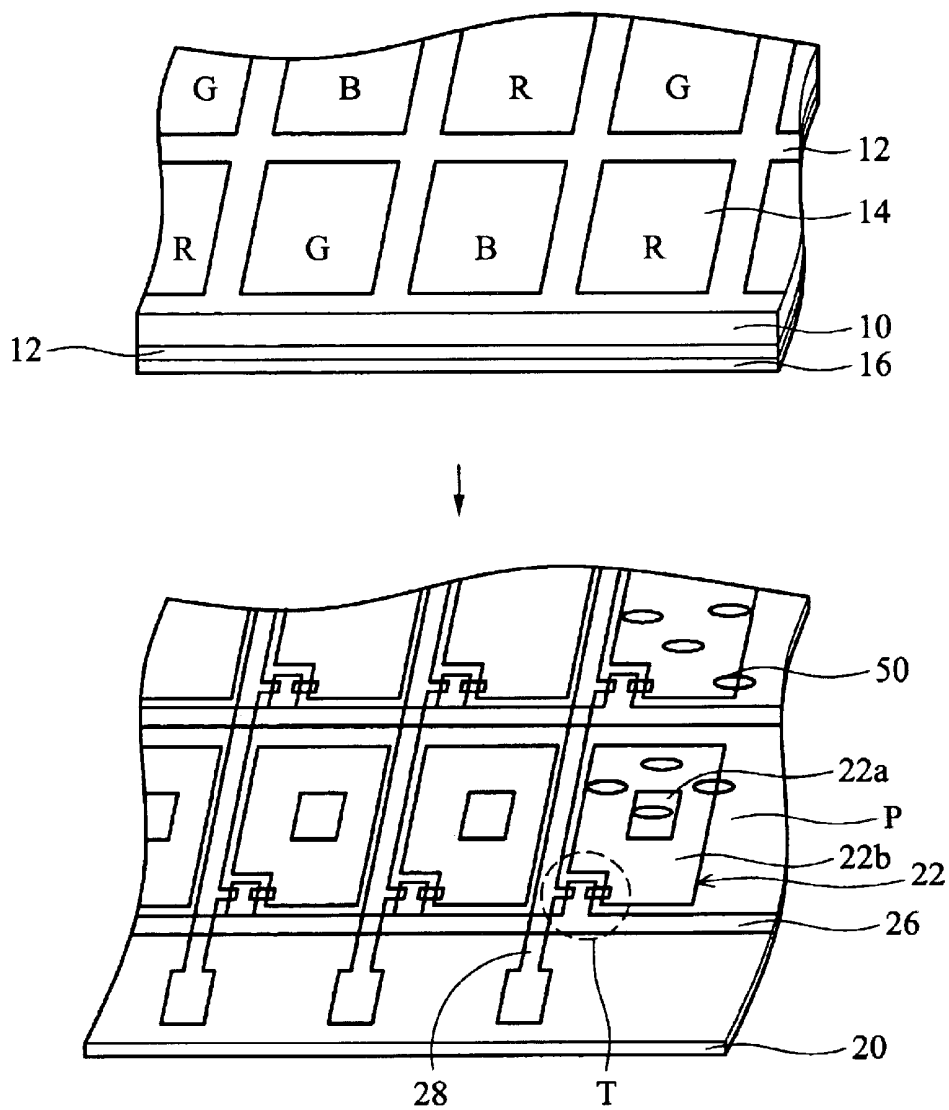


FIG. 1 (PRIOR ART)

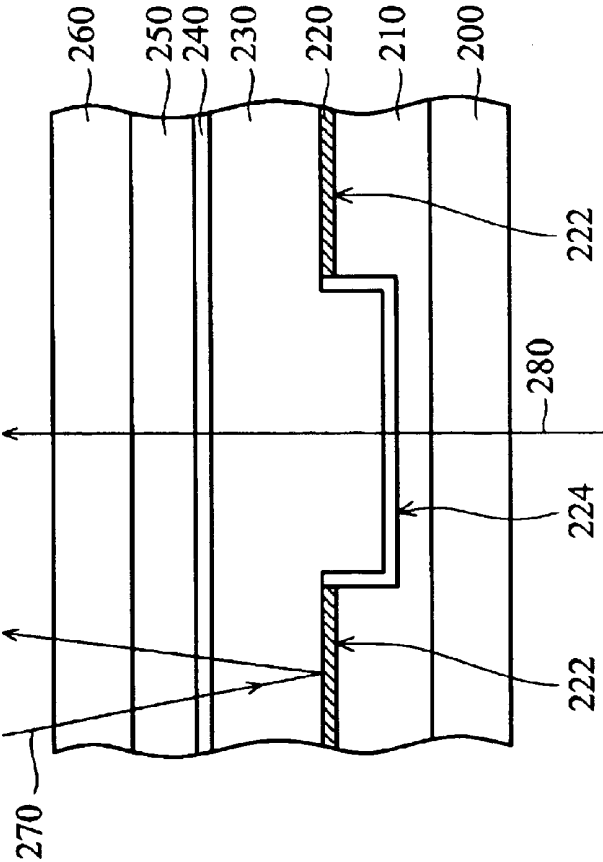


FIG. 2 (PRIOR ART)

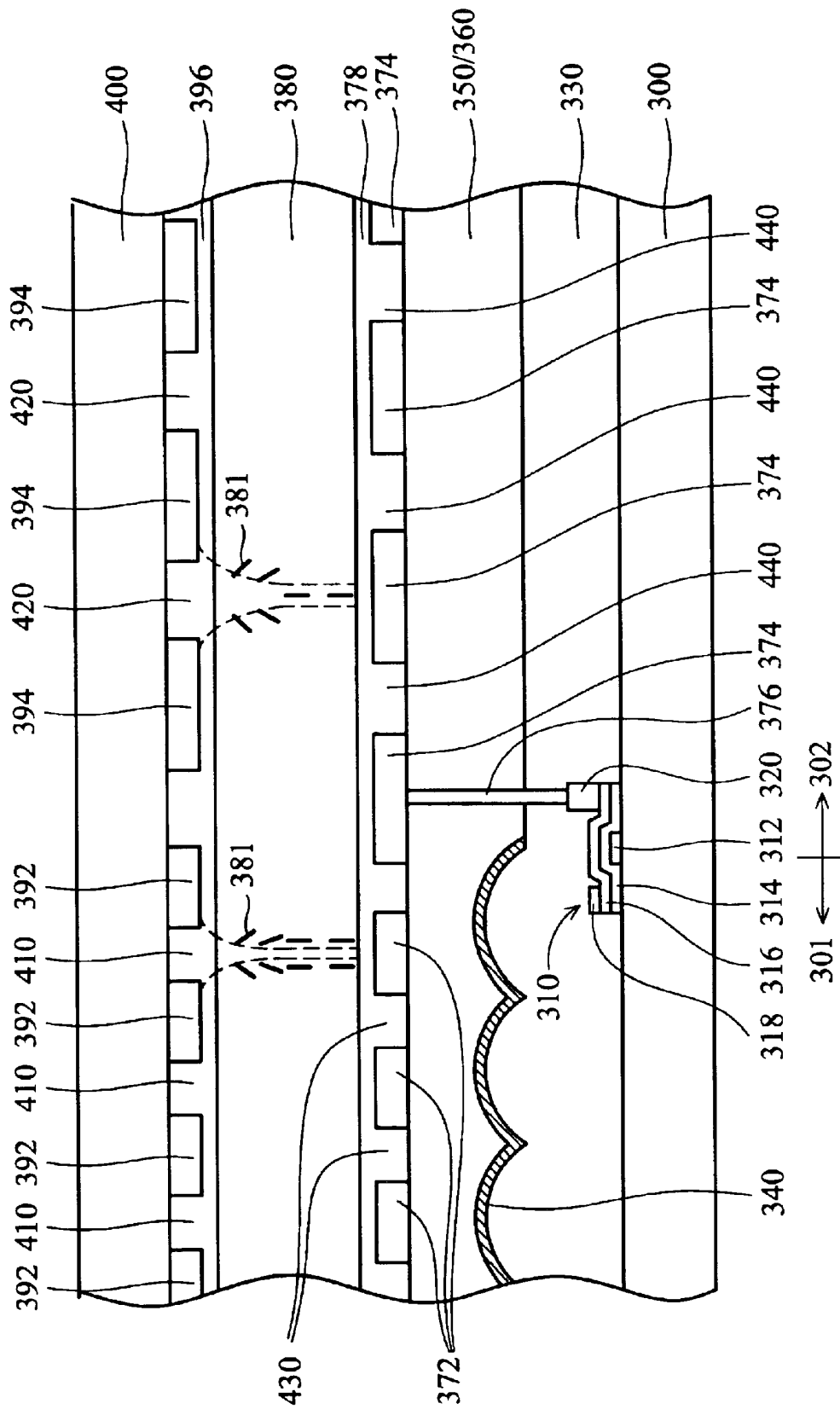


FIG. 3

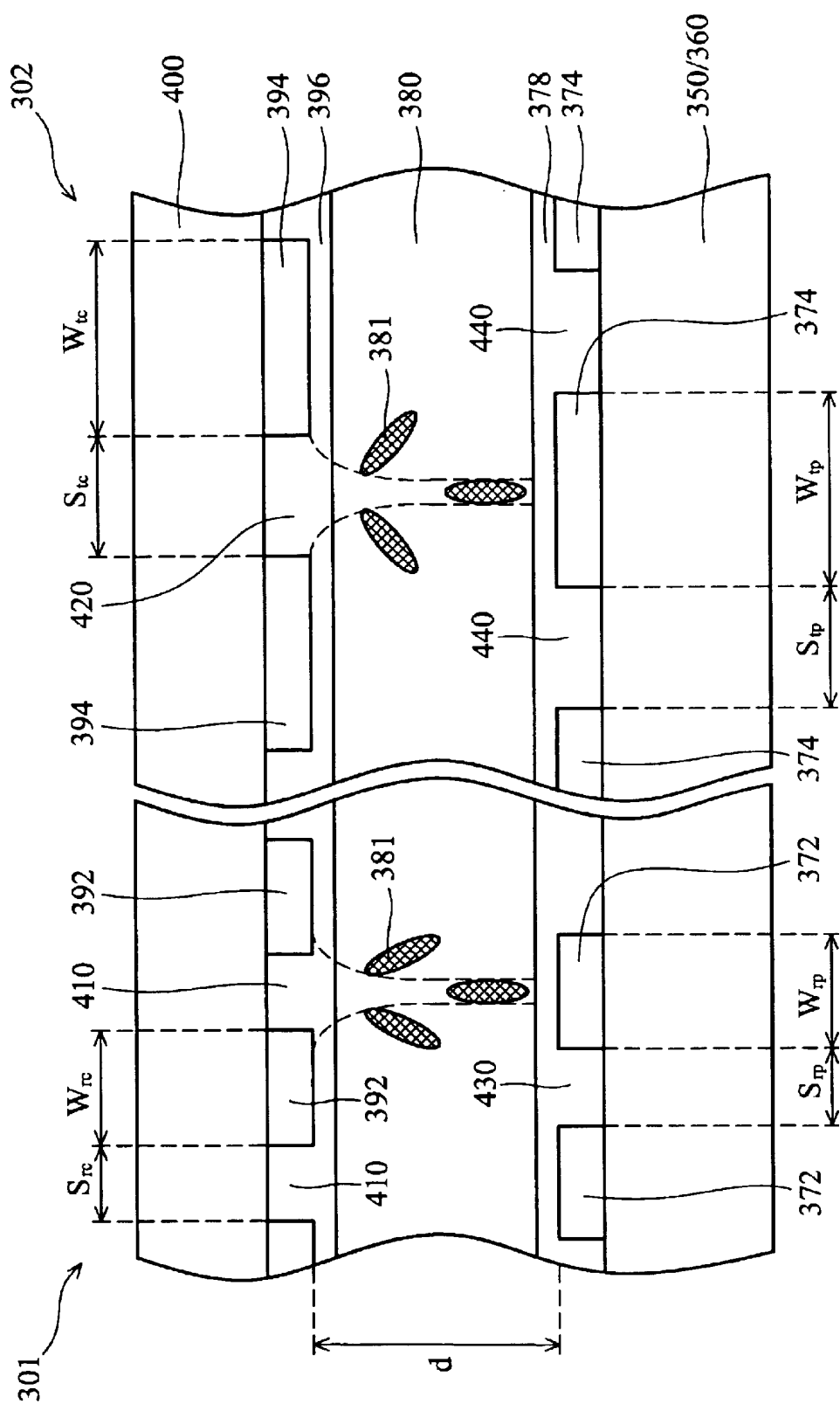


FIG. 4

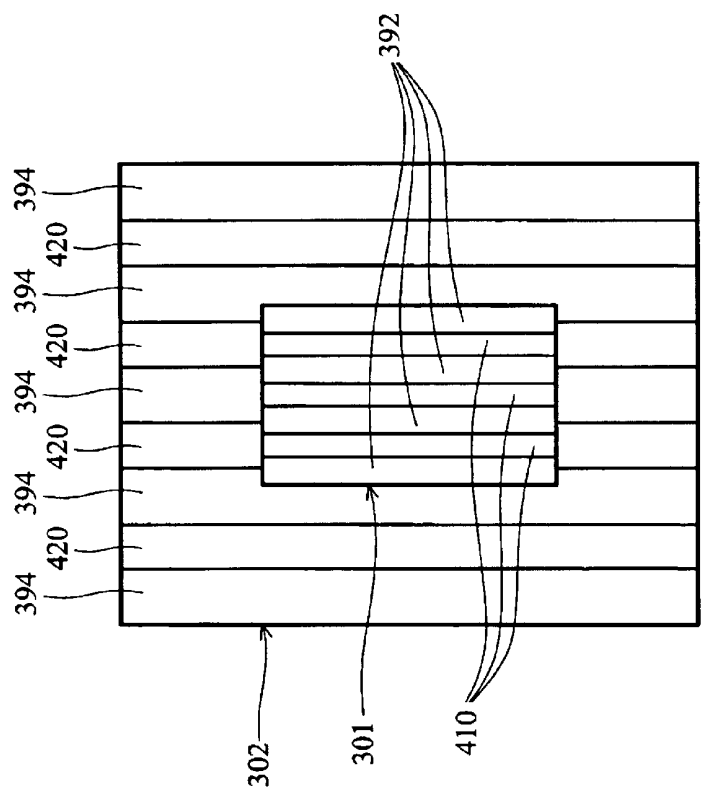


FIG. 5A

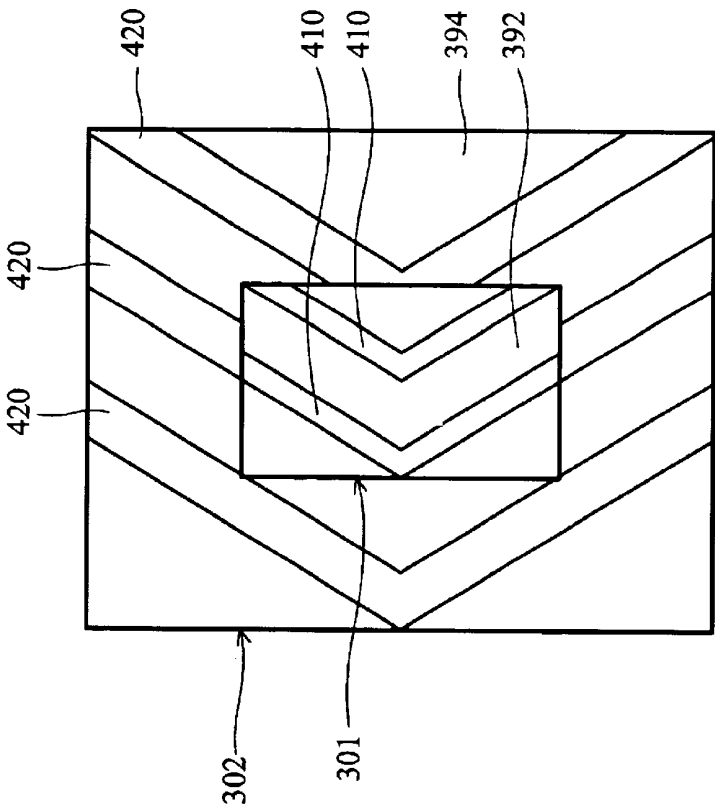


FIG. 5B

TRANSFLECTIVE LIQUID CRYSTAL DISPLAY DEVICE AND FABRICATION METHOD THEREOF

BACKGROUND OF THE INVENTION

1. Field of the Invention

The present invention relates to a vertically aligned (VA) transflective liquid crystal display device, and more particularly, to a VA transflective liquid crystal display device with a single cell gap.

2. Description of the Related Art

Liquid crystal display (LCD) devices are widely used for portable televisions, notebook computers and other applications. Liquid crystal display devices are classified into transmissive devices using a backlight as a light source, and reflective devices using an external light source, such as sunlight or indoor lamp. It is difficult to conserve weight, volume, and power consumption of transmissive LCDs due to the power requirements of the backlight component. Reflective LCDs have the advantage of no backlight component, but cannot operate without an external light source.

An alternative to these types of LCDs is a transflective LCD device which can operate both reflectively and transmissively. Transflective LCD devices have a reflective electrode in a pixel region, wherein the reflective electrode has a transmissive portion. Thus, the transflective LCD device features lower power consumption than conventional transmissive LCD devices because no backlight component used when there is a bright external light. Further, the transflective LCD device has the advantage of operating as a transmissive LCD, using a backlight when required.

FIG. 1 is an exploded perspective view of a typical transflective LCD device. The transflective LCD device comprises upper and lower substrates **10** and **20** opposed to each other, and an interposed liquid crystal layer **50** therebetween. The upper substrate **10** acts as a color filter substrate and the lower substrate **20** an array substrate. In the upper substrate **10**, black matrix **12** and color filter layer **14** including a plurality of red (R), green (G) and blue (B) color filters are formed. That is, the black matrix **12** surrounds each color filter, in the shape of an array matrix. Also on the upper substrate **10**, a common electrode **16** is formed to cover the color filter layer **14** and the black matrix **12**.

In the lower substrate **20**, a TFT "T" acting as a switching device, is formed in the shape of an array matrix corresponding to the color filter layer **14**. In addition, a plurality of crossing gate and data lines **26** and **28** are positioned such that each TFT is located near each intersection of the gate and data lines **26** and **28**. Further on the lower substrate **20**, a plurality of pixel regions (P) are defined by the gate and data lines **26** and **28**. Each pixel region P has a pixel electrode **22** comprising a transparent portion **22a** and an opaque portion **22b**. The transparent portion **22a** comprises a transparent conductive material, such as ITO (indium tin oxide) or IZO (indium zinc oxide), and the opaque portion **22b** comprises a metal having high reflectivity, such as Al (aluminum) or Ag (silver).

FIG. 2, a sectional view of a conventional transflective LCD device, illustrates the operation thereof. As shown in FIG. 2, the conventional transflective LCD device comprises a lower substrate **200**, an upper substrate **260** and an interposed liquid crystal layer **230**. The upper substrate **260** comprises a common electrode **240** and a color filter **250**

formed thereon. The lower substrate **200** comprises an insulating layer **210** and a pixel electrode **220** formed thereon, wherein the pixel electrode **220** comprises an opaque portion **222** and a transparent portion **224**. The opaque portion **222** of the pixel electrode **220** can be an aluminum layer, and the transparent portion **224** of the pixel electrode **220** can be an ITO (indium tin oxide) layer. The opaque portion **222** reflects ambient light **270**, while the transparent portion **224** transmits light **280** from a backlight device (not shown) disposed on the exterior of the lower substrate **200**. Also, there is a drop between the opaque portion **222** and the transparent portion **224**. The liquid crystal layer **230** is interposed between the lower and upper substrates **200** and **260**. In FIG. 2, the liquid crystal layer **230** comprises dual cell gaps. Generally, the material of the liquid crystal layer **230** comprises a twisted nematic (TN) type liquid crystal. Thus, the transflective LCD device is operable in both reflective and transmissive modes.

In U.S. Pat. No. 5,136,407, Clerc discloses avertically aligned LCD device. The LCD device has two groups of mutually crossing parallel electrodes sandwiching a liquid crystal layer, wherein the electrodes of one group comprise an aperture at each electrode intersection along the direction of and centrally at the electrode of the other group. The electric field at the aperture portion is constantly angled to a predetermined direction to present uniformly wide stable display areas. This method is usually applied to widen the viewing angle of the LCD, featuring slits separated by the same distance and utilizing liquid crystal molecules with negative dielectric anisotropy.

The conventional structure of slits between electrodes, nevertheless, is not presently applied to the transflective LCD device. Moreover, when the transflective LCD device uses the conventional method with equal spacing between slits, display brightness differs dramatically between the transmissive region and the reflective region. That is, the conventional configuration cannot achieve maximum light efficiency in both transmissive and reflective modes in the transflective LCD device.

SUMMARY OF THE INVENTION

One object of the present invention is to provide a transflective liquid crystal display device with a single cell gap, providing maximum light efficiency in both transmissive and reflective modes.

Yet another object of the present invention is to provide a method of forming an integrated color filter having various thicknesses on an array substrate, which causes requisite color purity in both transmissive and reflective mode.

In order to achieve these objects, the present invention provides a transflective liquid crystal display device with a single cell gap, wherein the transflective LCD device comprises a reflective region and a transmissive region. A first substrate and a second substrate opposite thereto are provided. A plurality of first pixel electrodes and a plurality of second pixel electrodes are formed overlying the first substrate, the first pixel electrodes located in the reflective region and the second pixel electrodes in the transmissive region. A plurality of first common electrodes and a plurality of second common electrodes are formed on an inner surface of the second substrate, the first common electrodes located in the reflective region and the second common electrodes in the transmissive region. A vertically aligned liquid crystal layer is interposed between the first substrate and the second substrate, wherein orientation of the vertically aligned liquid crystal layer is controlled by an electric field between the

pixel electrodes and the common electrodes. A first orientation control window having a slit width " S_{rc} " is formed between the first common electrodes in an area corresponding to each first pixel electrode and divides the liquid crystal layer into a plurality of orientation sections. A second orientation control window having a slit width " S_{tc} " is formed between the second common electrodes in an area corresponding to each second pixel electrode and divides the liquid crystal layer into a plurality of orientation sections. A relationship between S_{rc} and S_{tc} satisfies $S_{rc} < S_{tc}$.

In order to achieve these objects, the present invention also provides a method of manufacturing a transfective liquid crystal display device with a single cell gap, wherein the transfective LCD device comprises a reflective region and a transmissive region. A first substrate and a second substrate opposite thereto are provided. A reflective layer is formed on the first substrate in the reflective region. A transparent planarization layer or a color filter is formed overlying the reflective layer and the first substrate. A plurality of first pixel electrodes and a plurality of second pixel electrodes are formed overlying the transparent planarization layer or the color filter, wherein the first pixel electrodes are located in the reflective region and the second pixel electrodes are located in the transmissive region. A plurality of first common electrodes and a plurality of second common electrodes are formed on an inner surface of the second substrate, wherein the first common electrodes are located in the reflective region and the second common electrodes are located in the transmissive region. Liquid crystal molecules fill a space between the first substrate and the second substrate to form a vertically aligned liquid crystal layer, wherein orientation of the vertically aligned liquid crystal layer is controlled by an electric field between the pixel electrodes and the common electrodes. A first orientation control window having a slit width " S_{rc} " is formed between the first common electrodes in an area corresponding to each first pixel electrode and divides the vertically aligned liquid crystal layer into a plurality of orientation sections. A second orientation control window having a slit width " S_{tc} " is formed between the second common electrodes in an area corresponding to each second pixel electrode and divides the vertically aligned liquid crystal layer into a plurality of orientation sections. A relationship between S_{rc} and S_{tc} satisfies $S_{rc} < S_{tc}$.

The present invention improves on the conventional technology in that the first orientation control window having a slit width " S_{rc} " is formed between the first common electrodes in an area corresponding to each first pixel electrode. The second orientation control window having a slit width " S_{tc} " is formed between the second common electrodes in an area corresponding to each second pixel electrode. Specially, a relationship between " S_{rc} " and " S_{tc} " satisfies $S_{rc} < S_{tc}$. According to the present invention, the effective birefringence (Δn_{eff}) in the reflective region can be different from that in the transmissive region, thereby achieving maximum light efficiency in both reflective and transmissive modes under saturation voltage and ameliorating the disadvantages of the conventional technology.

BRIEF DESCRIPTION OF THE DRAWINGS

The present invention can be more fully understood by reading the subsequent detailed description in conjunction with the examples and references made to the accompanying drawings, wherein:

FIG. 1 is an exploded perspective view of a typical transfective LCD device;

FIG. 2 is a sectional view of a transfective LCD device according to the conventional technology, illustrating the operation thereof;

FIG. 3 is a sectional view of a transfective LCD device with a single cell gap according to the present invention;

FIG. 4 is an explanatory diagram showing the tilt angles of liquid crystal molecules and the configuration of the present invention;

FIG. 5A is a plane view showing a layout example of the orientation control window of the present invention; and

FIG. 5B is a plane view showing another layout example of the orientation control window of the present invention.

DETAILED DESCRIPTION OF THE INVENTION

Reference will now be made in detail to the present preferred embodiments of the invention, examples of which are illustrated in the accompanying drawings. Wherever possible, the same reference numbers are used in the drawings and the description to refer to the same or like parts.

FIG. 3 is a sectional view of a transfective LCD device with a single cell gap according to the present invention. In order to simplify the illustration, FIG. 3 shows a substrate in a single pixel region, although pixel regions may be numerous.

A first substrate **300** serving as a lower substrate comprises a predetermined reflective region (or section) **301** and a predetermined transmissive region (or section) **302**. The first substrate **300** may be a heat-resistant glass substrate.

A pixel driving device array overlies the first substrate **300**. The pixel driving device array may be a thin film transistor (TFT) **310** array. The TFT device **310** comprises a gate **312**, a gate insulating layer **314**, a semiconductor layer **316**, a source electrode **318** and a drain electrode **320**. The source electrode **318** and the drain electrode **320** are interchangeable.

An insulating layer **330** blanketly overlies the first substrate **300** to cover the TFT **310** array. An exemplary method of forming the insulating layer **330** follows. A photosensitive resin layer is coated over the first substrate **300**. A UV photolithography procedure using a photomask is performed. A partial development and a curing treatment are then performed to form the insulating layer **330**. The surface of the insulating layer **330** can be smooth or uneven in the reflective region **301**, preferably, uneven. The surface of the insulating layer **330** is smooth in the transmissive region **302**. It should be noted that the top surface of the insulating layer **330** in the reflective region **301** is higher than that in the transmissive region **302**.

A conformal reflective layer **340** overlies the insulating layer **330** in the reflective region **301**. The reflective layer **340** can be an aluminum or silver layer formed by deposition and partial etching.

A transparent planarization layer **350** (also referred to as a passivation layer) or a layer of color filter **360** overlies the reflective layer **340** and the insulating layer **330**. The transparent planarization layer **350** can be a SiO_2 or SOG (spin-on-glass) layer formed by deposition or coating. The color filter **360** can comprise a red (R) region, a green (G) region and a blue (B) region, which can be formed by pigment dispersion, inkjet, or other processes. It should be noted that, since the color filter **360** in the reflective region **301** is thinner than in the transmissive region **302**, the total route length of ambient light (or reflective light, not shown) passing through the color filter **360** in the reflective region

301 is similar to that of the backlight (not shown) penetrating the color filter **360** in the transmissive region **302**. That is, the total route length of the backlight and the ambient light passing through the color filter **360** are approximate, thereby improving color reproduction (color purity) between the reflective and transmissive modes. In order to simplify the illustration, the color filter **360** is represented hereinafter.

A plurality of first pixel electrodes **372** and a plurality of second pixel electrodes **374** are disposed on the color filter **360**. The first pixel electrodes **372** are located in the reflective region **301** and the second pixel electrodes **374** in the transmissive region **302**. The pixel electrodes **372** and **374** can be ITO (indium tin oxide) or IZO (indium zinc oxide) layers formed by deposition and partial etching. The thickness of each pixel electrode **372/374** is about 500 Å. Additionally, the pixel electrodes **372** and **374** electrically connect the TFT device **310** by means of a conductive plug **376**. Then, an alignment film **378** can overlie the pixel electrodes **372** and **374**. It is not necessary to perform a rubbing treatment on the alignment film **378**.

A second substrate **400** serving as an upper substrate is opposite the first substrate **300**. The second substrate **400** may be a glass substrate. A plurality of first common electrodes **392** and a plurality of second common electrodes **394** are disposed on an inner surface of the second substrate **400**. The first common electrodes **392** are located in the reflective region **301** and the second common electrodes **394** in the transmissive region **302**. The common electrodes **392** and **394** can be ITO (indium tin oxide) or IZO (indium zinc oxide) layers formed by deposition and partial etching. The thickness of each common electrode **392/394** is about 500 Å. Additionally, an alignment film **396** can overlie the common electrodes **392** and **394**. It is not necessary to perform a rubbing treatment on the alignment film **396**.

Negative type ($\Delta\epsilon < 0$) liquid crystal molecules **381** fill a space between the first and second substrates **300** and **400** to form a vertically aligned (VA) type liquid crystal layer **380**. The orientation of the vertically aligned liquid crystal layer **380** is controlled by an electric field (shown by dotted lines) between the pixel electrodes **372**, **374** and the common electrodes **392**, **394**. It should be noted that there is a single gap "d", referring to FIG. 4, between the pixel electrodes **372**, **374** and the common electrodes **392**, **394**. That is, the thickness of the liquid crystal layer **380** is uniform. For example, the gap "d" ranges from 3 to 5 μm .

Moreover, at least one compensation film (not shown) and polarizer (not shown) can be disposed on exterior sides of the substrates **300** and **400**.

FIG. 4 is an enlarged diagram of a portion of the transreflective LCD device, illustrating features of the present invention.

A first orientation control window **410** having a slit width " S_{rc} " is formed between the first common electrodes **392** in an area corresponding to each first pixel electrode **372** and divides the vertically aligned liquid crystal layer **380** into a plurality of orientation sections. A second orientation control window **420** having a slit width " S_{tc} " is formed between the second common electrodes **394** in an area corresponding to each second pixel electrode **374** and divides the vertically aligned liquid crystal layer **380** into a plurality of orientation sections. Specially, a relationship between S_{rc} and S_{tc} satisfies $S_{rc} < S_{tc}$.

Since the electric field applied to the liquid crystal molecules **381** located below the orientation windows **410** and **420** is not sufficiently strong to tilt these molecules **381**, they have nearly vertical alignment (i.e. the tilt angle is very

small). Around these molecules **381**, however, an electric field is created as indicated by the dotted line in FIGS. 3 and 4, which controls the molecules **381** to direct their longer axes perpendicular to the applied field. Due to the fringe field effect, the tilt angle of the molecules **381** near the orientation windows **410** and **420** is larger.

Each first common electrode **392** has an electrode width " W_{rc} " and each second common electrode **394** an electrode width " W_{tc} ". Specially, a relationship between W_{rc} and W_{tc} satisfies $W_{rc} < W_{tc}$.

In addition, a first opening **430** having a slit width " S_{rp} " is formed between the first pixel electrodes **372** in an area corresponding to each first common electrode **392**. A second opening **440** having a slit width " S_{tp} " is formed between the second pixel electrodes **374** in an area corresponding to each second common electrode **394**. Specially, a relationship between S_{rp} and S_{tp} satisfies $S_{rp} < S_{tp}$.

Each first pixel electrode **372** has an electrode width " W_{rp} " and each second pixel electrode **374** has an electrode width " W_{tp} ". Specially, a relationship between W_{rp} and W_{tp} satisfies $W_{rp} < W_{tp}$.

It is preferred that, for symmetry, the first orientation control window **410** approximately faces a center part of each first pixel electrode **372**, the second orientation control window **420** approximately faces a center part of each second pixel electrode **374**, the first opening **430** approximately faces a center part of the first common electrode **392** and the second opening **440** approximately faces a center part of the second common electrode **394**.

Size conditions of this preferred embodiment are illustrated, but are not intended to limit the present invention.

The slit width " S_{rc} " of the first orientation control window **410** ranges from 3 μm to 7 μm .

The slit width " S_{tc} " of the second orientation control window **420** ranges from 8 μm to 12 μm .

The electrode width " W_{rc} " of each first common electrode **392** ranges from 5 μm to 15 μm .

The electrode width " W_{tc} " of each second common electrode **394** ranges from 15 μm to 25 μm .

The slit width " S_{rp} " of the first opening **430** ranges from 3 μm to 7 μm .

The slit width " S_{tp} " of the second opening **440** ranges from 8 μm to 12 μm .

The electrode width " W_{rp} " of each first pixel electrode **372** ranges from 5 μm to 15 μm .

The electrode width " W_{tp} " of each second pixel electrode **374** ranges from 15 μm to 25 μm .

The gap "d" formed between the pixel electrodes **372/374** and the common electrodes **392/394** ranges from 3 μm to 5 μm .

It should be noted that, in this embodiment, S_{rc} can equal S_{rp} , S_{tc} can equal S_{tp} , W_{rc} can equal W_{rp} and W_{tc} can equal W_{tp} .

As regards the layout of the orientation windows **410** and **420**, two layout examples are illustrated, but are not intended to limit the present invention. FIG. 5A shows a configuration of the first orientation control window **410** and the second orientation control window **420** is a straight striped pattern. FIG. 5B shows another configuration of the first orientation control window **410** and the second orientation control window **420** is a wedge-shaped (or an arrowhead) pattern.

Due to the slit width " S_{rc} " of the first orientation control window **410** being less than that " S_{tc} " of the second orien-

tation control window 420, the directional variation of the fringe field near the first orientation control window 410 is smaller than that near the second orientation control window 420. Thus, the tilt angle of the molecules 381 near the first orientation control window 410 is smaller than that near the second orientation control window 420. This causes an effective birefringence (Δn_{eff}) in the reflective region 301 different from that in the transmissive region 302 (e.g. the effective birefringence in the transmissive region 302 (Δn_{eff-t}) is about twice than that in the reflective region 301 (Δn_{eff-r})), thereby achieving maximum light efficiency in both reflective and transmissive modes under saturation voltage. That is, according to the present invention, the retardation under the reflective mode ($\Delta n_{eff-r} * 2d$) approximates that under the transmissive mode ($\Delta n_{eff-t} * d$), thereby achieving maximum display brightness in both modes under saturation voltage.

The present invention provides a transfective LCD device with a single cell gap, and fabrication method thereof. The first orientation control window having a slit width " S_{rc} " is formed between the first common electrodes, wherein the first orientation control window faces each first pixel electrode. The second orientation control window having a slit width " S_{rc} " is formed between the second common electrodes, wherein the second orientation control window faces each second pixel electrode. Specially, a relationship between " S_{rc} " and " S_{tc} " satisfies $S_{rc} < S_{tc}$. Thus, the tilt angle of the liquid crystal molecules is different in the reflective region and the transmissive region, thereby causing different effective birefringence therebetween. This invention creates an approximate retardation in both reflective and transmissive modes under saturation voltage, thereby achieving maximum light efficiency and ameliorating the disadvantages of the conventional technology.

Finally, while the invention has been described by way of example and in terms of the above, it is to be understood that the invention is not limited to the disclosed embodiments. On the contrary, it is intended to cover various modifications and similar arrangements as would be apparent to those skilled in the art. Therefore, the scope of the appended claims should be accorded the broadest interpretation so as to encompass all such modifications and similar arrangements.

What is claimed is:

1. A transfective liquid crystal display (LCD) device with a single cell gap, comprising:
 - a first substrate and a second substrate opposite thereto, wherein the transfective LCD device comprises a reflective region and a transmissive region;
 - a plurality of first pixel electrodes and a plurality of second pixel electrodes on the first substrate, the first pixel electrodes in the reflective region and the second pixel electrodes in the transmissive region;
 - a plurality of first common electrodes and a plurality of second common electrodes on an inner surface of the second substrate, the first common electrodes in the reflective region and the second common electrodes in the transmissive region;
 - a vertically aligned liquid crystal layer interposed between the first substrate and the second substrate, wherein orientation of the vertically aligned liquid crystal layer is controlled by an electric field between the pixel and common electrodes;
 - a first orientation control window having a slit width " S_{rc} " between the first common electrodes in an area corresponding to each first pixel electrode and dividing the liquid crystal layer into a plurality of orientation sections; and

a second orientation control window having a slit width " S_{tc} " between the second common electrodes in an area corresponding to each second pixel electrode and dividing the liquid crystal layer into a plurality of orientation sections;

wherein a relationship between S_{rc} and S_{tc} satisfies $S_{rc} < S_{tc}$.

2. The transfective LCD device according to claim 1, wherein each first common electrode comprises an electrode width " W_{rc} " and each second common electrode comprises an electrode width " W_{tc} ", and a relationship between W_{rc} and W_{tc} satisfies $W_{rc} < W_{tc}$.

3. The transfective LCD device according to claim 1, further comprising:

a first opening having a slit width " S_{rp} " between the first pixel electrodes in an area corresponding to each first common electrode; and

a second opening having a slit width " S_{tp} " between the second pixel electrodes in an area corresponding to each second common electrode;

wherein a relationship between S_{rp} and S_{tp} satisfies $S_{rp} < S_{tp}$.

4. The transfective LCD device according to claim 2, wherein each first pixel electrode comprises an electrode width " W_{rp} " and each second pixel electrode comprises an electrode width " W_{tp} ", and a relationship between W_{rp} and W_{tp} satisfies $W_{rp} < W_{tp}$.

5. The transfective LCD device according to claim 1, wherein the slit width " S_{rc} " of the first orientation control window ranges from 3 μm to 7 μm .

6. The transfective LCD device according to claim 1, wherein the slit width " S_{tc} " of the second orientation control window ranges from 8 μm to 12 μm .

7. The transfective LCD device according to claim 2, wherein the electrode width " W_{rc} " of each first common electrode ranges from 5 μm to 15 μm .

8. The transfective LCD device according to claim 2, wherein the electrode width " W_{tc} " of each second common electrode ranges from 15 μm to 25 μm .

9. The transfective LCD device according to claim 3, wherein the slit width " S_{rp} " of the first opening ranges from 3 μm to 7 μm .

10. The transfective LCD device according to claim 3, wherein the slit width " S_{tp} " of the second opening ranges from 8 μm to 12 μm .

11. The transfective LCD device according to claim 4, wherein the electrode width " W_{rp} " of each first pixel electrode ranges from 5 μm to 15 μm .

12. The transfective LCD device according to claim 4, wherein the electrode width " W_{tp} " of each second pixel electrode ranges from 15 μm to 25 μm .

13. The transfective LCD device according to claim 1, further comprising a gap "d" between the pixel and common electrodes, ranging from 3 μm to 5 μm .

14. The transfective LCD device according to claim 1, wherein configuration of the first orientation control window and the second orientation control window is a straight striped pattern.

15. The transfective LCD device according to claim 1, wherein configuration of the first orientation control window and the second orientation control window is a wedge-shaped pattern.

16. The transfective LCD device according to claim 1, further comprising:

an insulating layer on the first substrate;

a reflective layer on the insulating layer in the reflective region; and

a transparent planarization layer on the reflective layer and the insulating layer;
 wherein a top surface of the insulating layer in the reflective region is higher than that in the transmissive region.

17. The transfective LCD device according to claim 1, further comprising:

an insulating layer on the first substrate;
 a reflective layer on the insulating layer in the reflective region; and
 a color filter on the reflective layer and the insulating layer;
 wherein a top surface of the insulating layer in the reflective region is higher than that in the transmissive region.

18. The transfective LCD device according to claim 3, wherein S_{rc} equals S_{rp} and S_{tc} equals S_{tp} .

19. The transfective LCD device according to claim 4, wherein W_{rc} equals W_{rp} and W_{tc} equals W_{tp} .

20. The transfective LCD device according to claim 3, wherein the first orientation control window faces a center part of each first pixel electrode, the second orientation control window faces a center part of each second pixel electrode, the first opening faces a center part of the first common electrode and the second opening faces a center part of the second common electrode.

21. A method of fabricating a transfective liquid crystal display device, comprising the steps of:

providing a first substrate and a second substrate opposite thereto, wherein the transfective LCD device has a reflective region and a transmissive region;

forming a reflective layer overlying the first substrate in the reflective region;

forming a transparent planarization layer or a color filter overlying the reflective layer and the first substrate;

forming a plurality of first pixel electrodes and a plurality of second pixel electrodes on the transparent planarization layer or the color filter, wherein the first pixel electrodes are located in the reflective region and the second pixel electrodes in the transmissive region;

forming a plurality of first common electrodes and a plurality of second common electrodes on an inner surface of the second substrate, wherein the first common electrodes are located in the reflective region and the second common electrodes in the transmissive region; and

filling a space between the first substrate and the second substrate with liquid crystal molecules to form a vertically aligned liquid crystal layer interposed between the first substrate and the second substrate, wherein orientation of the vertically aligned liquid crystal layer is controlled by an electric field between the pixel and common electrodes;

wherein a first orientation control window having a slit width " S_{rc} " is formed between the first common electrodes in an area corresponding to each first pixel electrode, dividing the vertically aligned liquid crystal layer into a plurality of orientation sections;

wherein a second orientation control window having a slit width " S_{tc} " is formed between the second common electrodes in an area corresponding to each second pixel electrode, dividing the vertically aligned liquid crystal layer into a plurality of orientation sections; wherein a relationship between S_{rc} and S_{tc} satisfies $S_{rc} < S_{tc}$.

22. The method according to claim 21, wherein each first common electrode has an electrode width " W_{rc} " and each second common electrode an electrode width " W_{tc} ", and a relationship between W_{rc} and W_{tc} satisfies $W_{rc} < W_{tc}$.

23. The method according to claim 21, further comprising the steps of:

forming a first opening having a slit width " S_{rp} " between the first pixel electrodes in an area corresponding to each first common electrode; and

forming a second opening having a slit width " S_{tp} " between the second pixel electrodes in an area corresponding to each second common electrode; wherein a relationship between S_{rp} and S_{tp} satisfies $S_{rp} < S_{tp}$.

24. The method according to claim 22, wherein each first pixel electrode has an electrode width " W_{rp} " and each second pixel electrode an electrode width " W_{tp} ", and a relationship between W_{rp} and W_{tp} satisfies $W_{rp} < W_{tp}$.

25. The method according to claim 21, wherein the slit width " S_{rc} " of the first orientation control window ranges from $3\ \mu\text{m}$ to $7\ \mu\text{m}$.

26. The method according to claim 21, wherein the slit width " S_{tc} " of the second orientation control window ranges from $8\ \mu\text{m}$ to $12\ \mu\text{m}$.

27. The method according to claim 22, wherein the electrode width " W_{rc} " of each first common electrode ranges from $5\ \mu\text{m}$ to $15\ \mu\text{m}$.

28. The method according to claim 22, wherein the electrode width " W_{tc} " of each second common electrode ranges from $15\ \mu\text{m}$ to $25\ \mu\text{m}$.

29. The method according to claim 23, wherein the slit width " S_{rp} " of the first opening ranges from $3\ \mu\text{m}$ to $7\ \mu\text{m}$.

30. The method according to claim 23, wherein the slit width " S_{tp} " of the second opening ranges from $8\ \mu\text{m}$ to $12\ \mu\text{m}$.

31. The method according to claim 24, wherein the electrode width " W_{rp} " of each first pixel electrode ranges from $5\ \mu\text{m}$ to $15\ \mu\text{m}$.

32. The method according to claim 24, wherein the electrode width " W_{tp} " of each second pixel electrode ranges from $15\ \mu\text{m}$ to $25\ \mu\text{m}$.

33. The method according to claim 21, wherein a gap "d" is formed between the pixel and common electrodes, ranging from $3\ \mu\text{m}$ to $5\ \mu\text{m}$.

34. The method according to claim 21, wherein configuration of the first orientation control window and the second orientation control window is a straight striped pattern.

35. The method according to claim 21, wherein configuration of the first orientation control window and the second orientation control window is a wedge-shaped pattern.

36. The method according to claim 21, wherein the common electrodes are ITO (indium tin oxide) or IZO (indium zinc oxide) layers.

37. The method according to claim 21, wherein the pixel electrodes are ITO (indium tin oxide) or IZO (indium zinc oxide) layers.

38. The method according to claim 21, wherein the reflective layer is an aluminum or silver layer.

39. The method according to claim 21, wherein the transparent planarization layer is a SiO_2 layer.

40. The method according to claim 21, wherein the liquid crystal molecules are negative type ($\Delta\epsilon < 0$).

41. The method according to claim 23, wherein S_{rc} is equal to S_{rp} and S_{tc} equals S_{tp} .

42. The method according to claim 24, wherein W_{rc} is equal to W_{rp} and W_{tc} equals W_{tp} .

43. The method according to claim 23, wherein the first orientation control window faces a center part of each first pixel electrode, the second orientation control window faces a center part of each second pixel electrode, the first opening

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faces a center part of the first common electrode and the second opening faces a center part of the second common electrode.

44. The method according to claim **21**, wherein an insulating layer is formed on the first substrate before forming

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the reflective layer and a top surface of the insulating layer in the reflective region is higher than that in the transmissive region.

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申请(专利权)人(译)	张清CHAO		
当前申请(专利权)人(译)	瀚宇彩晶股份有限公司.		
[标]发明人	CHANG CHING CHAO		
发明人	CHANG, CHING CHAO		
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摘要(译)

具有单个单元间隙的透反射LCD装置。第一和第二像素电极形成在下基板上。第一和第二公共电极形成在上基板的内表面上。第一像素电极和第一公共电极位于反射区域中。第二像素电极和第二公共电极位于透射区域中。具有狭缝宽度“Src”的第一取向控制窗口形成在与每个第一像素电极对应的区域中的第一公共电极之间。在第二公共电极之间形成具有狭缝宽度“Stc”的第二取向控制窗口，满足 $Src < Stc$ 。第二取向控制窗口位于与每个第二像素电极对应的区域中。因此，可以在反射和透射模式下实现最大光效率。

